

ALEXANDRIA, VA 22313-1450

8-24-07

In re Patent No. 7,014,958

Issue Date: 3/21/2006

Appl No.: 10/604,181 Filed: June 30, 2003

For: Method for Dry Etching Photomask Material

DECISION DISMISSING

PETITION

37 CFR 1.324

This is a decision on the petition under 37 CFR 1.48, filed 3/10/2004. In view of the fact that the patent has already issued, the request under 37 CFR 1.48 has been treated as a petition to correct inventorship under 37 CFR 1.324.

The petition is dismissed.

A petition to correct inventorship as provided by 37 CFR 1.324 requires (1) a statement from each person who is being added as an inventor that the inventorship error occurred without any deceptive intention on their part, (2) a statement from the current named inventors (including any "inventor" being deleted) who have not submitted a statement as per "(1)" either agreeing to the change of inventorship or stating that they have no disagreement in regard to the requested change, (3) a statement from all assignees of the parties submitting a statement under "(1)" and "(2)" agreeing to the change of inventorship in the patent; such statement must comply with the requirements of 37 CFR 3.73(b); and (4) the fee set forth in 37 CFR 1.20(b). This petition lacks item(s): statements from the current named inventors agreeing to the change of inventorship or stating that they have no disagreement in regard to the requested change.

Mark F. Huff

Supervisory Patent Examiner

Art Unit 1756

Patent Examining Group 1700

MCGUIRE WOODS LLP 1750 TYSONS BLVD. **SUITE 1800** MCLEAN, VA 22102-4215